DISCRETE SEMICONDUCTORS



1996 Feb 12

File under Discrete Semiconductors, SC08b



Philips Semiconductors

QUALITY

Total Quality Management

Philips Semiconductors is a Quality Company, renowned for the high quality of our products and service. We keep alive this tradition by constantly aiming towards one ultimate standard, that of zero defects. This aim is guided by our Total Quality Management (TQM) system, the basis of which is described in the following paragraphs.

QUALITY ASSURANCE

Based on ISO 9000 standards, customer standards such as Ford TQE and IBM MDQ. Our factories are certified to ISO 9000 by external inspectorates.

PARTNERSHIPS WITH CUSTOMERS

PPM co-operations, design-in agreements, ship-to-stock, just-in-time and self-qualification programmes, and application support.

PARTNERSHIPS WITH SUPPLIERS

Ship-to-stock, statistical process control and ISO 9000 audits.

QUALITY IMPROVEMENT PROGRAMME

Continuous process and system improvement, design improvement, complete use of statistical process control, realization of our final objective of zero defects, and logistics improvement by ship-to-stock and just-in-time agreements.

Advanced quality planning

During the design and development of new products and processes, quality is built-in by advanced quality planning. Through failure-mode-and-effect analysis (FMEA) the critical parameters are detected and measures taken to ensure good performance on these parameters. The capability of process steps is also planned in this phase.

Product conformance

The assurance of product conformance is an integral part of our quality assurance (QA) practice. This is achieved by:

- Incoming material management through partnerships with suppliers.
- In-line quality assurance to monitor process reproducibility during manufacture and initiate any necessary corrective action. Critical process steps are 100% under statistical process control.

- Acceptance tests on finished products to verify conformance with the device specification. The test results are used for quality feedback and corrective actions. The inspection and test requirements are detailed in the general quality specifications.
- Periodic inspections to monitor and measure the conformance of products.

Product reliability

With the increasing complexity of Original Equipment Manufacturer (OEM) equipment, component reliability must be extremely high. Our research laboratories and development departments study the failure mechanisms of semiconductors. Their studies result in design rules and process optimization for the highest built-in product reliability. Highly accelerated tests are applied to the products reliability evaluation. Rejects from reliability tests and from customer complaints are submitted to failure analysis, to result in corrective action.

Customer responses

Our quality improvement depends on joint action with our customer. We need our customers' inputs and we invite constructive comments on all aspects of our performance. Please contact our local sales representative.

Recognition

The high quality of our products and services is demonstrated by many Quality Awards granted by major customers and international organizations.

PRO ELECTRON TYPE NUMBERING

Basic type number

This type designation code applies to discrete semiconductor devices (not integrated circuits), multiples of such devices, semiconductor chips and Darlington transistors.

FIRST LETTER

The first letter gives information about the material for the active part of the device.

- A Germanium or other material with a band gap of 0.6 to 1 eV
- B Silicon or other material with a band gap of 1 to 1.3 eV
- C Gallium arsenide (GaAs) or other material with a band gap of 1.3 eV or more
- R Compound materials, e.g. cadmium sulphide.

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SECOND LETTER

The second letter indicates the function for which the device is primarily designed. The same letter can be used for multi-chip devices with similar elements.

In the following list low power types are defined by $R_{th j-mb} > 15$ K/W and power types by $R_{th j-mb} \le 15$ K/W.

- A Diode; signal, low power
- B Diode; variable capacitance
- C Transistor; low power, audio frequency
- D Transistor; power, audio frequency
- E Diode; tunnel
- F Transistor; low power, high frequency
- G multiple of dissimilar devices/miscellaneous devices; e.g. oscillators. Also with special third letter, see under "Serial number"
- H Diode; magnetic sensitive
- L Transistor; power, high frequency
- N Photocoupler
- P Radiation detector; e.g. high sensitivity photo-transistor; with special third letter
- Q Radiation generator; e.g. LED, laser; with special third letter
- R Control or switching device; e.g. thyristor, low power; with special third letter
- S Transistor; low power, switching
- T Control and switching device; e.g. thyristor, power; with special third letter
- U Transistor; power, switching
- W Surface acoustic wave device
- X Diode; multiplier, e.g. varactor, step recovery
- Y Diode; rectifying, booster
- Z Diode; voltage reference or regulator, transient suppressor diode; with special third letter.

SERIAL NUMBER

The number comprises three figures running from 100 to 999 for devices primarily intended for consumer equipment, or one letter (Z, Y, X, etc.) and two figures running from 10 to 99 for devices primarily intended for industrial or professional equipment.⁽¹⁾.

Version letter(s)

One or two letters may be added to the basic type number to indicate minor electrical or mechanical variants of the basic type. The letters never have a fixed meaning, except that the letter 'R' indicates reverse polarity and the letter 'W' indicates a surface mounted device (SMD).

RATING SYSTEMS

The rating systems described are those recommended by the IEC in its publication number 134.

Definitions of terms used

ELECTRONIC DEVICE

An electronic tube or valve, transistor or other semiconductor device. This definition excludes inductors, capacitors, resistors and similar components.

CHARACTERISTIC

A characteristic is an inherent and measurable property of a device. Such a property may be electrical, mechanical, thermal, hydraulic, electro-magnetic or nuclear, and can be expressed as a value for stated or recognized conditions. A characteristic may also be a set of related values, usually shown in graphical form.

BOGEY ELECTRONIC DEVICE

An electronic device whose characteristics have the published nominal values for the type. A bogey electronic device for any particular application can be obtained by considering only those characteristics that are directly related to the application.

RATING

A value that establishes either a limiting capability or a limiting condition for an electronic device. It is determined for specified values of environment and operation, and may be stated in any suitable terms. Limiting conditions may be either maxima or minima.

RATING SYSTEM

The set of principles upon which ratings are established and which determine their interpretation. The rating system indicates the division of responsibility between the device manufacturer and the circuit designer, with the object of ensuring that the working conditions do not exceed the ratings.

When the supply of these serial numbers is exhausted, the serial number may be expanded to three figures for industrial types and four figures for consumer types.

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Absolute maximum rating system

Absolute maximum ratings are limiting values of operating and environmental conditions applicable to any electronic device of a specified type, as defined by its published data, which should not be exceeded under the worst probable conditions.

These values are chosen by the device manufacturer to provide acceptable serviceability of the device, taking no responsibility for equipment variations, environmental variations, and the effects of changes in operating conditions due to variations in the characteristics of the device under consideration and of all other electronic devices in the equipment.

The equipment manufacturer should design so that, initially and throughout the life of the device, no absolute maximum value for the intended service is exceeded with any device, under the worst probable operating conditions with respect to supply voltage variation, equipment component variation, equipment control adjustment, load variations, signal variation, environmental conditions, and variations in characteristics of the device under consideration and of all other electronic devices in the equipment.

Design maximum rating system

Design maximum ratings are limiting values of operating and environmental conditions applicable to a bogey electronic device of a specified type as defined by its published data, and should not be exceeded under the worst probable conditions.

These values are chosen by the device manufacturer to provide acceptable serviceability of the device, taking responsibility for the effects of changes in operating conditions due to variations in the characteristics of the electronic device under consideration.

The equipment manufacturer should design so that, initially and throughout the life of the device, no design maximum value for the intended service is exceeded with a bogey electronic device, under the worst probable operating conditions with respect to supply voltage variation, equipment component variation, variation in characteristics of all other devices in the equipment, equipment control adjustment, load variation, signal variation and environmental conditions.

Design centre rating system

Design centre ratings are limiting values of operating and environmental conditions applicable to a bogey electronic device of a specified type as defined by its published data, and should not be exceeded under normal conditions.

These values are chosen by the device manufacturer to provide acceptable serviceability of the device in average applications, taking responsibility for normal changes in operating conditions due to rated supply voltage variation, equipment component variation, equipment control adjustment, load variation, signal variation, environmental conditions, and variations in the characteristics of all electronic devices.

The equipment manufacturer should design so that, initially, no design centre value for the intended service is exceeded with a bogey electronic device in equipment operating at the stated normal supply voltage.

DC CURRENT DRAINING

For RF power MOS transistors, the DC drain current rating is based on the maximum operating junction temperature of the device. The value specified will raise the temperature of the die to its maximum allowable temperature while the case is held at 25 °C. The power dissipation in the die equals $I_D^2 \times R_{DS(on)}$. From the maximum $R_{DS(on)}$ at $T_j = 200$ °C and the published values of maximum allowable dissipation, the current rating at $T_{mb} = 25$ °C is $(P_{D(max)}/R_{DS(on)})^{0.5}$.

LETTER SYMBOLS

The letter symbols for transistors detailed in this section are based on IEC publication number 148.

Basic letters

In the representation of currents, voltages and powers, lower-case letter symbols are used to indicate all instantaneous values that vary with time. All other values are represented by upper-case letters.

Electrical parameters⁽¹⁾ of external circuits and of circuits in which the device forms only a part are represented by upper-case letters. Lower-case letters are used for the representation of electrical parameters inherent in the device. Inductances and capacitances are always represented by upper-case letters.

For the purpose of this publication, the term 'electrical parameters' applies to four-pole matrix parameters, elements of electrical equivalent circuits, electrical impedances and admittances, inductances and capacitances.

The following is a list of basic letter symbols used with semiconductor devices:

- B, b susceptance (imaginary part of an admittance)
- C capacitance
- G, g conductance (real part of an admittance)
- H, h hybrid parameter
- I, i current
- L inductance
- P, p power
- R, r resistance (real part of an impedance)
- V, v voltage
- X, x reactance (imaginary part of an impedance)
- Y, y admittance
- Z, z impedance.

Subscripts

Upper-case subscripts are used for the indication of:

- continuous (DC) values (without signal), e.g. $I_{\text{B}},\,I_{\text{D}}$
- instantaneous total values, e.g. i_B, i_D
- average total values, e.g. $I_{B(AV)}$, $I_{D(AV)}$
- peak total values, e.g. I_{BM} , I_{DM}
- root-mean-square total values, e.g. I_{B(RMS)}, I_{D(RMS)}.

Lower-case subscripts are used for the indication of values applying to the varying component alone:

- instantaneous values, e.g. ib, id
- root-mean-square values, e.g. $I_{b(rms)}$, $i_{d(rms)}$
- peak values, e.g. I_{bm}, i_{dm}
- average values, e.g. $I_{b(av)}$, $i_{d(av)}$.

The following is a list of subscripts used with basic letter symbols for semiconductor devices:

A, a	anode
amb	ambient
(AV), (av)	average value
B, b	base
(BO)	breakover
(BR)	breakdown
case	case
C, c	collector
С	controllable
D, d	drain
E, e	emitter

F, f	fall, forward (or forward transfer)
G, g	gate
Н	holding
h	heatsink
I, i	input
j-a	junction to ambient
j-mb	junction to mounting base
K, k	cathode
L	load
M, m	peak value
(min)	minimum
(max)	maximum
mb	mounting base
Ο, ο	as third subscript: the terminal not mentioned is open-circuit
(OV)	overload
P, p	pulse
Q, q	turn-off
R, r	as first subscript: reverse (or reverse transfer), rise. As second subscript: repetitive, recovery. As third subscript: with a specified resistance between the terminal not mentioned and the reference terminal
(RMS), (rms)	root-mean-square value
S, s	as first subscript: series, source, storage, stray, switching. As second subscript: surge (non-repetitive). As third subscript: short circuit between the terminal not mentioned and the reference terminal
stg	storage
th	thermal
то	threshold
tot	total
W	working
Х, х	specified circuit
Z, z	reference or regulator (zener)
1	input (four-pole matrix)
2	output (four-pole matrix).

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Applications and examples

TRANSISTOR CURRENTS

The first subscript indicates the terminal carrying the current (conventional current flow from the external circuit into the terminal is positive).

Examples: I_B , I_D , i_B , i_D , i_b , i_d , I_{bm} , I_{dm} .

TRANSISTOR VOLTAGES

A voltage is indicated by the first two subscripts: the first identifies the terminal at which the voltage is measured and the second the reference terminal or the circuit node. The second subscript may be omitted when there is no possibility of confusion.

Examples: V_{BE}, V_{GS}, v_{BE}, v_{GS}, v_{be}, v_{gs}, V_{bem}, V_{gsm}.

SUPPLY VOLTAGES OR CURRENTS

Supply voltages or supply currents are indicated by repeating the appropriate terminal subscript.

Examples: V_{DD} , V_{CC} , I_{EE} , I_{SS} .

A reference terminal is indicated by a third subscript.

Examples: V_{CCE}, V_{DDS}.

DEVICES WITH MORE THAN ONE TERMINAL OF THE SAME KIND

If a device has more than one terminal of the same kind, the subscript is formed by the appropriate letter for the terminal, followed by a number. Hyphens may be used to avoid confusion in multiple subscripts.

Examples:

- I_{B2} continuous (DC) current flowing into the second base terminal
- I_{G2} continuous (DC) current flowing into the second gate terminal
- V_{B2-E} continuous (DC) voltage between the terminals of second base and emitter terminals
- V_{G2-S} continuous (DC) voltage between the terminals of second gate and source terminals.

MULTIPLE DEVICES

For multiple unit devices, the subscripts are modified by a number preceding the letter subscript. Hyphens may be used to avoid confusion in multiple subscripts.

Examples:

I_{2C} continuous (DC) current flowing into the collector terminal of the second unit

- I_{2D} continuous (DC) current flowing into the drain terminal of the second unit
- V_{1C-2C} continuous (DC) voltage between the collector terminals of the first and second units.
- V_{1D-2D} continuous (DC) voltage between the drain terminals of the first and second units.

ELECTRICAL PARAMETERS

The upper-case variant of a subscript is used for the designation of static (DC) values.

Examples:

- h_{FE} static value of forward current transfer in common-emitter configuration (DC current gain)
- g_{FS} static value of forward transconductance in common-source configuration (DC current gain)
- R_E DC value of the external emitter resistance.
- R_{DS} DC value of the drain-source resistance.

The static value is the slope of the line from the origin to the operating point on the appropriate characteristic curve, i.e. the quotient of the appropriate electrical quantities at the operating point.

The lower-case variant of a subscript is used for the designation of small-signal values.

Examples:

h _{fe}	small-signal value of the short-circuit forward
	current transfer in common-emitter
	configuration
g fs	small-signal value of the short-circuit forward

- g_{fs} small-signal value of the short-circuit forward transconductance in common-source configuration
- $Z_i = R_i + jX_i$ small-signal value of input impedance

If more than one subscript is used, subscripts for which a choice of style is allowed, the subscripts chosen are all upper-case or all lower-case.

Examples: h_{FE}, y_{RE}, h_{fe}, g_{FS}.

FOUR-POLE MATRIX PARAMETERS

The first letter subscript (or double numeric subscript) indicates input, output, forward transfer or reverse transfer.

Examples: h_i (or h_{11}), h_o (or h_{22}), h_f (or h_{21}), h_r (or h_{12}).

A further subscript is used for the identification of the circuit configuration. When no confusion is possible, this further subscript may be omitted.

Examples: h_{fe} (or h_{21e}), h_{FE} (or h_{21E}).

DISTINCTION BETWEEN REAL AND IMAGINARY PARTS

If it is necessary to distinguish between real and imaginary parts of electrical parameters, no additional subscripts are used. If basic symbols for the real and imaginary parts exist, these may be used.

Examples: $Z_i = R_i + jX_i$, $y_{fe} = g_{fe} + jb_{fe}$.

If such symbols do not exist or are not suitable, the notation shown in the following examples is used.

Examples:

Re (h<6~_{ib}) etc. for the real part of h_{ib}

Im (h_{ib}) etc. for the imaginary part of h_{ib} .

MARKING CODES

For the purposes of matched pair applications, RF power MOS transistors are marked with a code that indicates their gate-source voltage range (see Table 1).

CODE	V _{GS}	CODE	V _{GS}
0	1.00 to 1.10	J	2.80 to 2.90
1	1.10 to 1.20	К	2.90 to 3.00
2	1.20 to 1.30	L	3.00 to 3.10
3	1.30 to 1.40	М	3.10 to 3.20
4	1.40 to 1.50	Ν	3.20 to 3.30
5	1.50 to 1.60	0	3.30 to 340
6	1.60 to 1.70	Р	3.40 to 3.50
7	1.70 to 1.80	Q	3.50 to 3.60
8	1.80 to 1.90	R	3.60 to 3.70
9	1.90 to 2.00	S	3.70 to 3.80
A	2.00 to 2.10	Т	3.80 to 3.90
В	2.10 to 2.20	U	3.90 to 4.00
С	2.20 to 2.30	V	4.00 to 4.10
D	2.30 to 2.40	W	4.10 to 4.20
E	2.40 to 2.50	Х	4.20 to 4.30
F	2.50 to 2.60	Y	4.30 to 4.40
G	2.60 to 2.70	Z	4.40 to 4.50
Н	2.70 to 2.80		

Table 1 Marking codes for V_{GS} selection

MOUNTING AND SOLDERING (SOT223)

Mounting methods

There are two basic forms of electronic component construction, those with leads for through-hole mounting and microminiature types for surface mounting (SMD). Through-hole mounting gives a very rugged construction and uses well established soldering methods. Surface mounting has the advantages of high packing density plus high-speed automated assembly. Surface mounting techniques are complex and this chapter gives only a simplified overview of the subject.

Although many electronic components are available as surface mounting types, some are not and this often leads to the use of through-hole as well as surface mounting components on one substrate (a mixed print). The mix of components affects the soldering methods that can be applied. A substrate having SMDs mounted on one or both sides but no through-hole components is likely to be suitable for reflow or wave soldering. A double sided mixed print that has through-hole components and some SMDs on one side and densely packed SMDs on the other normally undergoes a sequential combination of reflow and wave soldering. When the mixed print has only through-hole components on one side and all SMDs on the other, wave soldering is usually applied.

Reflow soldering

This is the preferred soldering technique for SOT223 components.

SOLDER PASTE

Most reflow soldering techniques utilize a paste that is a mixture of flux and solder. The solder paste is applied to the substrate before the components are placed. It is of sufficient viscosity to hold the components in place and, therefore, an application of adhesive is not required. Drying of the solder paste by preheating increases the viscosity and prevents any tendency for the components to become displaced during the soldering process. Preheating also minimizes thermal shock and drives off flux solvents.

Screen printing

This is the best high-volume production method of solder paste application. An emulsion-coated, fine mesh screen with apertures etched in the emulsion to coincide with the surfaces to be soldered is placed over the substrate. A squeegee is passed across the screen to force solder paste through the apertures and on to the substrate.

The layer thickness of screened solder paste is usually between 150 and 200 $\mu\text{m}.$

Stencilling

In this method a stencil with etched holes to pass the paste is used. The thickness of the stencil determines the amount of amount of solder paste that is deposited on the substrate. This method is also suited to high-volume work.

Dispensing

A computer-controlled pressure syringe dispenses small doses of paste to where it is required. This method is mainly suitable for small production runs and laboratory use.

Pin transfer

A pin picks up a droplet of solder paste from a reservoir and transfers it to the surface of the substrate or component. A multi-pin arrangement with pins positioned to match the substrate is possible and this speeds up the process time.

REFLOW TECHNIQUES

Thermal conduction

The prepared substrates are carried on a conveyor belt, first through a preheating stage and then through a soldering stage. Heat is transferred to the substrate by conduction through the belt. Figure 1 shows a theoretical time/temperature relationship for thermal conduction reflow soldering. This method is particularly suited to thick film substrates and is often combined with infrared heating.

Infrared

An infrared oven has several heating elements giving a broad spectrum of infrared radiation, normally above and below a closed loop belt system. There are separate zones for preheating, soldering and cooling. Dwell time in the soldering zone is kept as short as possible to prevent damage to components and substrate. A typical heating profile is shown in Fig.2. This reflow method is often applied in double-sided prints.





Vapour phase

A substrate is immersed in the vapours of a suitable boiling liquid. The vapours transfer latent heat of condensation to the substrate and solder reflow takes place. Temperature is controlled precisely by the boiling point of the liquid at a given pressure. Some systems employ two vapour zones, one above the other. An elevator tray, suspended from a hoist mechanism passes the substrate vertically through the first vapour zone into the secondary soldering zone and then hoists it out of the vapour to be cooled. A theoretical time/temperature relationship for this method is shown in Fig.3.



Wave soldering

This soldering technique can be applied to SOT223 components.

ADHESIVE APPLICATION

Since there are no connecting wires to retain them, leadless and short-leaded components are held in place

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with adhesive for wave soldering. A spot of adhesive is carefully placed between each SMD and the substrate. The adhesive is then heat-cured to withstand the forces of the soldering process, during which the components are fully immersed in solder. There are several methods of adhesive application.

Pin transfer method

A pin is used to transfer a droplet of adhesive from a reservoir to a precise position on the surface where it is required. The size of the droplet depends on pin diameter, depth to which the pin is dipped in the reservoir, rheology of the adhesive, and the temperature of adhesive and surrounds. The pin can be part of a pin array (bed of nails) that corresponds exactly with the required adhesive positions on the substrate. With this method, adhesive can be applied to the whole of one side of a substrate in one operation and is therefore suitable for high-volume production and can be used with pre-loaded mixed prints.

Alternatively, pins can be used to transfer adhesive to the components before they are placed on the substrate. This adds flexibility to production runs where variations in layout must be accommodated.

Screen printing method

A fine mesh screen is coated with emulsion except in the positions where the adhesive is required to pass. The screen is placed on the substrate and a squeegee passing across it forces adhesive through the uncoated parts of the screen. The amount of adhesive printed-through depends on the size of the uncoated screen areas, the thickness of the screen coating, the rheology of the adhesive and various machine parameters. With this method, the substrate must be flat and pre-loaded mixed prints cannot be accommodated.

Pressure syringe method

A computer-controlled syringe dispenses adhesive from an enclosed reservoir by means of pulses of compressed air. The adhesive dot size depends on the size of the syringe nozzle, the duration and pressure of the pulsed air and the viscosity of the adhesive. This method is most suited to low volume production. An advantage is the flexibility provided by computer programmability.

FLUXING

The quality of the soldered connections between components and substrate is critical for circuit performance and reliability. Flux promotes solderability of the connecting surfaces and is chosen for the following attributes:

- · Removal of surface oxides
- Prevention of reoxidation
- Transference of heat from source to joint area
- Residue that is non-corrosive or, if residue is corrosive, should be easy to clean away after soldering
- Ability to improve wettability (readiness of a metal surface to form an alloy at its interface with the solder) to ensure strong joints with low electrical resistance
- Suitability for the desired method of flux application.

In wave soldering, liquified flux is usually applied as a foam, a spray or in a wave.

Foam

Flux foam is made by forcing low-pressure, water-free clean air through an aerator immersed in liquid flux. Fine bubbles of flux are directed onto the substrate/component surfaces where they burst and form a thin, even layer. The flux also penetrates any plated-through holes. The flux has to be chosen for its foaming capabilities.

Spray

Several methods of spray fluxing exist, the most common involves a mesh drum rotating in liquid flux. Air is blown into the drum which, when passing through the fine mesh, directs a spray of flux onto the underside of the substrate. The amount of flux deposited is controllable by the speed of the substrate passing through the spray, the speed of rotation of the drum and the density of the flux.

Wave

A wave fluxer creates a double flowing wave of liquid flux which adheres to the surface as the substrate passes through. Wave height control is essential and a soft wipe-off brush is usually incorporated to remove excess flux from the substrate.

PRE-HEATING

Pre-heating of the substrate and components is performed immediately before soldering. This reduces thermal shock as the substrate enters the soldering process, causes the flux to become more viscous and accelerates the chemical action of the flux and so speeds up the soldering action.

SOLDERING

Wave soldering is usually the best method to use when high throughput rates are required. The single wave soldering principle (see Fig.4) is the most straight forward method and can be used on simple substrates with two-terminal SMD components. More complex substrates with increased circuit density and closer spacing of conductors can pose the problems of nonwetting (dry joints) and solder bridging. Bridging can occur across the closely spaced leads of multi-leaded devices as well as across adjacent leads on neighbouring components. Nonwetting is usually caused by components with plastic bodies. The plastic is not wetted by solder and creates a depression in the solder wave, which is augmented by surface tension. This can cause a shadow behind the component and prevent solder from reaching the joint surfaces. A smooth laminar solder wave is required to avoid bridging and a high pressure wave is needed to completely cover the areas that are difficult to wet. These conflicting demands are difficult to attain in a single wave but dual wave techniques go a long way in overcoming the problem.

In a dual wave machine (see Fig.5), the substrate first comes into contact with a turbulent wave which has a high vertical velocity. This ensures good solder contact with both edges of the components and prevents joints from being missed. The second smooth laminar wave completes the formation of the solder fillet, removes excess solder and prevents bridging. Figure 6 indicates the time/temperature relationship measured at the soldering site in dual wave soldering.

New methods of wave soldering are developing continually. For example, the Omega System is a single wave agitated by pulses, which combines the functions of smoothness and turbulence. In another, a lambda wave injects air bubbles in the final part of the wave. A further innovation is the hollow jet wave in which the solder wave flows in the opposite direction to the substrate.

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at the soldering site.

Footprint design

The footprint design of a component for surface mounting is influenced by many factors:

- Features of the component, its dimensions and tolerances
- Circuit board manufacturing processes
- Desired component density
- Minimum spacing between components
- · Circuit tracks under the component
- Component orientation (if wave soldering)
- · Positional accuracy of solder resist to solder lands
- Positional accuracy of solder paste to solder lands (if reflow soldering)
- Component placement accuracy
- Soldering process parameters
- Solder joint reliability parameters.

Hand soldering microminiature components

It is possible to solder microminiature components with a light-weight hand-held soldering iron, but this method has obvious drawbacks and should be restricted to laboratory use and/or incidental repairs on production circuits:

- Hand-soldering is time-consuming and therefore expensive.
- The component cannot be positioned accurately and the connecting tags may come into contact with the substrate and damage it.
- There is a risk of breaking the substrate and internal connections in the component could be damaged.
- The component package could be damaged by the iron.

THERMAL CONSIDERATIONS

Thermal resistance

Circuit performance and long-term reliability are affected by the temperature of the transistor die. Normally, both are improved by keeping the die temperature (junction temperature) low.

Electrical power dissipated in any semiconductor device is a source of heat. This increases the temperature of the die about some reference point, normally an ambient temperature of 25 °C in still air. The size of the increase in temperature depends on the amount of power dissipated in the circuit and the net thermal resistance between the heat source and the reference point.

Devices lose most of their heat by conduction when mounted on a a printed board, a substrate or heatsink. Referring to Fig.7 (for surface mounted devices mounted on a substrate), heat conducts from its source (the junction) via the package leads and soldered connections to the substrate. Some heat radiates from the package into the surrounding air where it is dispersed by convection or by forced cooling air. Heat that radiates from the substrate is dispersed in the same way.

The elements of thermal resistance shown in Fig.8 are defined as follows:

- $R_{th \ j\text{-mb}} \quad \ thermal \ resistance \ from \ junction \ to \ mounting \\ base$
- R_{th j-c} thermal resistance from junction to case
- R_{th j-s} thermal resistance from junction to soldering point
- R_{th c-a} thermal resistance from case to ambient
- R_{th j-a} thermal resistance from junction to ambient.



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The temperature at the junction depends on the ability of the package and its mounting to transfer heat from the junction region to the ambient environment. The basic relationship between junction temperature and power dissipation is:

where:

T_{amb} is the ambient temperature

P_{tot max} is the maximum power handling capability of the device, including the effects of external loads when applicable.

In the expression for $T_{j max}$, only T_{amb} and $R_{th s-a}$ can be varied by the user. The package mounting technique and the flow of cooling air are factors that affect $R_{th s-a}$. The device power dissipation can be controlled to a limited extent but under recommended usage, the supply voltage and circuit loading dictate a fixed power maximum. The $R_{th j-s}$ value is essentially independent of external mounting method and cooling air; but is sensitive to the materials used in the package construction, the die bonding method and the die area, all of which are fixed.

For applications where the temperature of the case is stabilized by a large or temperature-controlled heatsink, the junction temperature can be calculated from

 $T_{j} = T_{case} + P_{tot} \times R_{th j-c} \text{ or, using the soldering point}$ definition, from $T_{j} = T_{solder} + P_{tot} \times R_{th j-s}$.

Values of $T_{j max}$ and $R_{th j-s}$, or $R_{th j-c}$ or $R_{th j-a}$ are given in the device data sheets.

Thermal resistance (R_{th s-a})

The thermal resistance from soldering point to ambient, and that from case to ambient depends on the shape and material of the tracks and substrate as illustrated in Figure 9.



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FLAGE-MOUNTED POWER TRANSISTORS

Mounting recommendations

- Ensure holes in heatsinks are free from burrs.
- Minimum depth of tapped holes in heatsinks is 6 mm.
- Use 4-40 UNC-2A cheese-head screws with a flat washer to spread the joint pressure.
- For transistors dissipating up to 80 W, the heatsink thickness should be at least 3 mm copper (> 99.9% ETP-Cu) or 5 mm aluminium (99% Al). The thickness of the heatsink should be increased proportionally for transistors dissipating more power.
- The minimum flatness of the mounting area is 0.02 mm.
- Mounting area roughness should be less than 0.5 μ m.
- Avoid, as much as possible, use of flux or flux solutions because flux can penetrate even hermetically sealed ceramic-capped transistors. Tin and wash the printed-circuit boards **before** mounting the power transistors, then solder the transistors into place without using flux.
- Transistor leads may be tinned by dipping them full-length into a solder bath at a temperature of about 230 °C. No flux should be used during tinning.
- Recommended heatsink compounds: WPS II (silicone-free) from Austerlitz-Electronics; Comp. Trans. from KF; 340 from Dow Corning; Trans-Heat from E. Friis-Mikkelsen.
- When a transistor is removed from a heatsink, the flange, almost certainly, will have been distorted by the joint pressure. Grinding or lapping of the flange to the required flatness and smoothness is necessary before the transistor is remounted.

Mounting sequence

- Apply a thin layer of evenly-distributed heatsink compound to the flange.
- Position the device with flat washers in place.
- Tighten the screws until finger-tight (0.05 Nm).
- Further tighten the screws until the specified torque is reached (do not lubricate); for torques, refer to the package outlines section of this data handbook.
- To lock mounting screws, allow about 30 minutes for them to bed-down after the specified torque has been applied, re-tighten to the specified torque and apply locking paint.

Mounting recommendations SOT365

To ensure a good thermal contact and to prevent mechanical stresses when bolted down, the flatness of the mounting base is designed to be typically better than 100 μ m. The mounting area of the heatsink should be flat and free from burrs and loose particles. The heatsink should be rigid and not prone to bowing under thermal cycling conditions. The thickness of a solid heatsink should not be less than 5 mm, to ensure a rigid assembly.

A thin, even layer of thermal compound should be used between the mounting base and the heatsink to achieve the best possible thermal conduction. Excessive use of thermal compound will result in an increase in thermal resistance and possible bowing of the mounting base; too little will also result in poor thermal conduction.

The module should be mounted to the heatsink using 3 mm bolts with flat washers. The bolts should first be tightened to "finger tight" and then further tightened in alternating steps to a maximum torque of 0.4 to 0.6 Nm.

Once mounted on the heatsink, the module leads can be soldered to the printed-circuit board. A soldering iron may be used up to a temperature of 250 °C for a maximum of 10 seconds at a distance of 2 mm from the plastic cap. ESD precautions must be taken to protect the device from electro-static damage.

Mounting recommendations SOT409

Both the metallized ground plate and leads contribute to the heatflow. For the best results it is recommended to mount the transistor on a grounded metallized area on the printed-circuit board equipped with a large number of metallized through-holes filled with solder. A thermal resistance ($R_{th\ mb-h}$) of 0.9 K/W can be achieved if a heatsink compound is used when the printed-circuit board is mounted on the heatsink.

Thermal behaviour

The coefficients of linear thermal expansion (α) shown in Table 2 can be used to calculate the thermal expansion of the different header parts.

SYMBOL	PACKAGE	FLANGE	LEAD FRAME	UNIT
	SOT119	- 18.3 × 10 ⁻⁶	7.5×10^{-6} to 8.5×10^{-6}	K ⁻¹
	SOT123			
	SOT171			
α	SOT273			
-	SOT262	6.5 × 10 ⁻⁶	7.5×10^{-6} to 8.5×10^{-6}	K-1
	SOT268			
	SOT324			

 Table 2
 Coefficients of linear thermal expansion of flange-mounted packages

CAPSTAN HEADERS

 Table 3
 Mounting data for capstan headers

ITEM	MO				
ITEM	1/4″	1/4" 3/8" 1/2"		TOLERANCE	UNIT
Thread	8-32 UNC-2A(B)	10-32 UNF-2A(B)	¹ / ₄ " × 28 UNF-2A(B)	_	_
Maximum diameter of threaded stud	4.14	4.80	6.33	_	mm
Diameter of heatsink mounting hole	4.15	4.85	6.35	+0.05/-0	mm
Mounting nut thickness	3.5 and 5	5	5.5	_	mm
Mounting nut torque:					
minimum	0.75	1.5	2.3	_	Nm
maximum	0.85	1.7	2.7	_	Nm
Distance from heatsink to printed-circuit board	2.9	3.8	4.8	+0/-0.2	mm

Mounting recommendations

- Avoid, as much as possible, use of flux or flux solutions because flux can penetrate even hermetically sealed ceramic-capped transistors. Tin and wash the printed-circuit boards **before** mounting the power transistors, then solder the transistors into place without using flux.
- Transistor leads may be tinned by dipping them full-length into a solder bath at a temperature of about 230 °C. No flux should be used during tinning.
- Heatsink surfaces at the mounting hole are to be flat, parallel and free of burrs or oxidation.
- Do not use locking washers, their locking action can deteriorate in time due to the comparative softness of most heatsink materials. A flat washer can be used to spread the joint pressure.
- Ensure a positive clearance exists between leads and printed circuit board, this prevents upward lead-bending and consequent damage to the encapsulation
- Recommended heatsink compounds: WPS II (silicone-free) from Austerlitz-Electronics; Comp. Trans. from KF; 340 from Dow Corning; Trans-Heat from E. Friis-Mikkelsen.
- The full mounting nut torque should be applied only once in the life of a transistor. For pre-assembly testing, apply no more than two-thirds of the specified torque.

Mounting sequence

- Apply a thin layer of evenly-distributed heatsink compound to the heatsink.
- Position the device with a flat washer in place.
- Tighten the screws until finger-tight (0.05 Nm).
- Further tighten the screws until the specified torque is reached (do not lubricate); for torques, refer to the package outline section of this data handbook.
- To lock mounting screws, allow about 30 minutes for them to bed-down after the specified torque has been applied, re-tighten to the specified torque and apply locking paint.

HANDLING MOS DEVICES

Electrostatic charges

Electrostatic charges can exist in many things; for example, man-made-fibre clothing, moving machinery, objects with air blowing across them, plastic storage bins, sheets of paper stored in plastic envelopes, paper from electrostatic copying machines, and people. The charges are caused by friction between two surfaces, at least one of which is non-conductive. The magnitude and polarity of the charges depend on the different affinities for electrons of the two materials rubbing together, the friction force and the humidity of the surrounding air.

Electrostatic discharge is the transfer of an electrostatic charge between bodies at different potentials and occurs with direct contact or when induced by an electrostatic field. Our RF Power MOS transistors are sensitive to electrostatic discharge and, to avoid damage, the following precautions must be taken.

Work station

Figure 10 shows a working area suitable for safely handling electrostatic sensitive devices. It has a work bench, the surface of which is conductive or covered by an antistatic sheet. Typical resistivity for the bench surface is between 1 and 500 k Ω per cm². The floor should also be covered with antistatic material.

The following precautions should be observed:

- Persons at a work bench should be earthed via a wrist strap and a resistor.
- All mains-powered electrical equipment should be connected via an earth leakage switch.
- Equipment cases should be earthed.
- Relative humidity should be maintained between 50 and 65%.
- An ionizer should be used to neutralize objects with immobile static charges.

Receipt and storage

Our devices are packed for dispatch in antistatic conductive containers, usually boxes, tubes or blister tape. The fact that the contents are sensitive to electrostatic discharge is shown by warning labels on both primary and secondary packing.

The devices should be kept in their original packing whilst in storage. If a bulk container is partially unpacked, the unpacking should be performed at a protected work station. Any devices that are stored temporarily should be packed in conductive or antistatic packing or carriers.

Assembly

The devices must be removed from their protective packing with earthed component pincers or short-circuit clips. Short-circuit clips must remain in place during mounting, soldering and cleansing/drying processes. Do not remove more devices from the storage packing than

General

are needed at any one time. Production/assembly documents should state that the product contains electrostatic sensitive devices and that special precautions need to be taken.

All tools used during assembly, including soldering tools and solder baths, must be earthed. All hand tools should be of conductive or antistatic material and, where possible, should not be insulated.

Measuring and testing of completed circuit boards must be done at a protected work station. Place the soldered side of the circuit board on conductive or antistatic foam and remove the short-circuit clips. Remove the circuit board from the foam, holding the board only at the edges. Make sure the circuit board does not touch the conductive surface of the work bench. After testing, replace the circuit board on the conductive foam to await packing.

Assembled circuit boards should be handled in the same way as unmounted devices. They should also carry warning labels and be packed in conductive or antistatic packing.

